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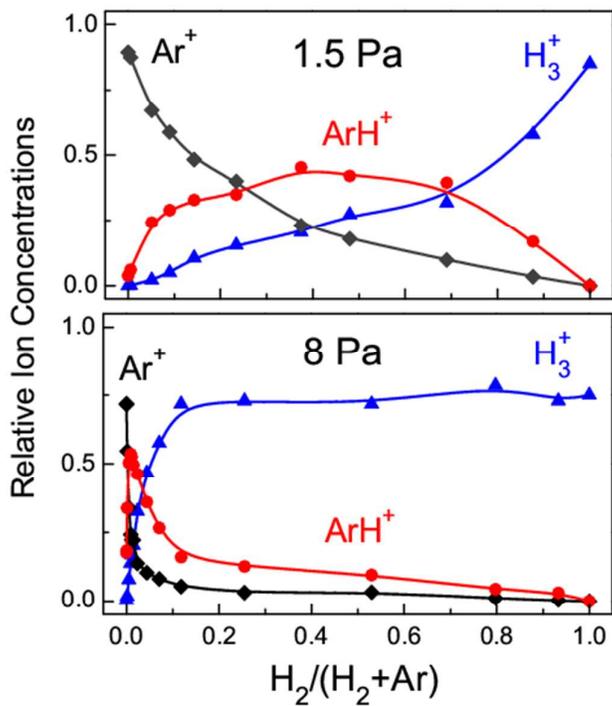
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“The only noble gas compound observed in space, ArH^+ , is investigated in cold Ar/H_2 laboratory plasmas”



Ion kinetics in Ar/H₂ cold plasmas: the relevance of ArH⁺

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Abstract

The recent discovery of ArH⁺ in the interstellar medium has awakened the interest in the chemistry of this ion. In this work, the ion-molecule kinetics of cold plasmas of Ar/H₂ is investigated in glow discharges spanning the whole range of [H₂]/([H₂]+[Ar]) proportions for two pressures, 1.5 and 8 Pa. Ion concentrations are determined by mass spectrometry, and electron temperatures and densities, with Langmuir probes. A kinetic model is used for the interpretation of the results. The selection of experimental conditions evinces relevant changes with plasma pressure in the ion distributions dependence with the H₂ fraction, particularly for the major ions: Ar⁺, ArH⁺ and H₃⁺. At 1.5 Pa, ArH⁺ prevails for a wide interval of H₂ fractions: $0.3 < [H_2]/([H_2]+[Ar]) < 0.7$. Nevertheless, a pronounced displacement of the ArH⁺ maximum towards the lowest H₂ fractions is observed at 8 Pa, in detriment of Ar⁺, which becomes restricted to very small [H₂]/([H₂]+[Ar]) ratios, whereas H₃⁺ becomes dominant for all [H₂]/([H₂]+[Ar]) > 0.1. The analysis of the data with the kinetic model allows the identification of the sources and sinks of the major ions over the whole range of experimental conditions sampled. Two key factors turn out to be responsible for the different ion distributions observed: the electron temperature, which determines the rate of Ar⁺ formation and thus of ArH⁺, and the equilibrium $ArH^+ + H_2 \rightleftharpoons H_3^+ + Ar$, which can be strongly dependent of the degree of vibrational excitation of H₃⁺. The results are discussed and compared with previously published data on other Ar/H₂ plasmas.

1. Introduction

In a recent article, Barlow et al.¹ reported the detection of the argonium ion ($^{36}\text{ArH}^+$) through its 617.525 and 1234.603 GHz emission lines in spectra from the Crab Nebula recorded in the course of the Herschel mission. It is the first noble gas compound observed hitherto in space. Barlow et al.¹ suggested that ArH^+ is formed most likely in transition zones between fully ionized and molecular gas and that electron collisions provide the likely excitation mechanism. Shortly afterwards, Schilke et al.² assigned to $^{36}\text{ArH}^+$ a previously unidentified absorption at 617.5 GHz in the diffuse interstellar medium (ISM), present in spectral line surveys toward many galactic sources. The two astronomically relevant $^{36}\text{ArH}^+$ and $^{38}\text{ArH}^+$ isotopologues of argonium were found in these surveys. From a careful analysis of the observations using a chemical model for diffuse molecular clouds, the authors concluded that ArH^+ should be a very good tracer of gas with very low (10^{-4} - 10^{-3}) fractional abundances of H_2 . The fresh discovery of ArH^+ in different chemical environments in the ISM has revived the interest in the mechanisms for the production and destruction of this ion.

In the laboratory, ArH^+ is usually produced in electrical discharges containing Ar and H_2 . The properties of different types of Ar/ H_2 discharges have been experimentally investigated and theoretically modeled by a number of research groups³⁻¹⁷ due largely to their interest for many technical applications like elemental analysis,¹⁸⁻²¹ sputtering,²²⁻²⁵ film deposition,^{26, 27} hydrogenation,^{28, 29} or functionalization of nanostructured materials.^{30, 31} Questions addressed in these studies include the loss of global ionization upon addition of H_2 to an Ar plasma, the modification of the electron energy distributions, the role of metastable Ar atoms and that of the excited states of H_2 , the reforming of precursors,³¹ or the distinct effects of physical and chemical sputtering on the characteristics of substrate films (see for instance discussions in refs.^{5, 10, 24, 29}). An illustrative example of the relevance of ArH^+ in a technological process can be found in the work of Budtz-Jørgensen et al.,²³ who found that highly energetic ArH^+ ions were responsible for most of the physical sputtering of gold surfaces in Ar/ H_2 dc discharges. In these plasmas the primary Ar^+ ions lose much of their energy, and thus of their sputtering efficiency, through symmetric charge exchange collisions with Ar atoms in the sheath before reaching the gold surface.

The ion chemistry in Ar/H₂ plasmas was also specifically considered, with varying degree of detail, in some of the works cited in the previous paragraph. Bogaerts and co-workers developed theoretical models for different types of glow discharges.¹⁰⁻¹² In their hybrid Monte Carlo fluid model for direct current, dc, discharges,¹⁰ Bogaerts and Gijbels simulated the conditions of a typical glow discharge used for analytic mass spectrometry (1% H₂ in Ar, 70 Pa). The model calculations yielded an ionic distribution dominated by Ar⁺, with ArH⁺ and H₃⁺ having also a significant presence, and with very small amounts of H⁺ and H₂⁺. Qualitatively similar ion distributions were also obtained in the modeling of a higher pressure (850 Pa) Grimm type dc discharge¹¹ and of a capacitively coupled radio frequency (rf) discharge¹² operated at lower pressures (7-33 Pa). The results of these models were of great help for the identification of key processes in the discharges, but could not be directly compared to experimental measurements.

Distributions of ion densities in inductively coupled rf discharges were also modeled, but not measured, in the recent works of Kimura and Kasugai¹³ and Hjartarson et al.¹⁴ They used self-consistent global models to study Ar/H₂ discharges with variable mixture proportions in the pressure ranges 2.7-8 Pa and 0.13-13 Pa, respectively. In both works, the major ions were also Ar⁺, H₃⁺ and ArH⁺, with different relative concentrations depending of the pressure and mixture conditions, but in no case was ArH⁺ the prevalent ion.

A detailed comparison of experimental ion distributions and model calculations for Ar/H₂ inductively coupled rf plasmas for a total pressure of 1 Pa was recently reported by Sode et al.^{16, 17} In contrast with the calculations of ref.¹³ and ref.¹⁴, the measurements of Sode et al. revealed that ArH⁺ was the dominant ion over much of the Ar fraction range investigated, where it accounted for roughly two thirds of the positive charge. Their model reproduced the overall trends in the evolution of the ion distributions, but underestimated the measured ArH⁺ concentration and overestimated the H_x⁺ densities. Sode et al.¹⁷ noted that their measurements and calculations would be in much better agreement by assuming a zero rate coefficient for the ArH⁺ + H₂ → H₃⁺ + Ar reaction, instead of the large literature values currently used, which are in the upper half of the 10⁻¹⁰ cm³ s⁻¹ range (see ref.³² and references therein).

A comparison of experimental and calculated ion density distributions in Ar/H₂ plasmas was also reported in a previous work by our group¹⁵ for a dc hollow cathode discharge. The experiments were carried out at pressures of 0.7 and 2 Pa for an [H₂]/([H₂]+[Ar]) ratio of 0.85. For this small Ar fraction the discharges were dominated by hydrogenic ions (H₃⁺ at 2 Pa and H₃⁺ and H₂⁺ for 0.7 Pa), but ArH⁺ ions were second in importance. The experiments also showed the presence of a small amount of Ar²⁺ ions. The measured ion distributions could be well accounted for by a kinetic model if a tiny fraction of high energy electrons (> 50 eV) was used in the calculations. Hollow cathodes and other types of dc glow discharges were used for spectroscopic studies of the ArH⁺ ion.³³⁻³⁹ In these works, the absolute concentration of ArH⁺ in the discharge was empirically maximized, and it was found that the largest ArH⁺ signals were obtained with a small H₂ fraction,³⁴⁻³⁸ or even with no H₂ at all^{33, 39} in the precursor mixture. This seeming paradox suggests that hydrogen from small impurities or from the reactor walls would be adequate to produce significant amounts of ArH⁺ in the plasma. In general, these discharges were run at higher pressures (> 30 Pa) than those commented on the previous paragraphs.

The present work intends to shed light on the details of the ionic chemistry in Ar/H₂ plasmas and, in particular, of the processes leading to the production and destruction of ArH⁺ for different plasma conditions. To this aim, we have used an approach combining a thorough experimental diagnosis of the plasmas (including the measurements of electron temperatures and densities, as well as the distributions of stable neutrals and ions) with a simple kinetic model of the ion chemistry. We have investigated hollow cathode discharges, spanning the whole range of [H₂]/([H₂]+[Ar]) mixture proportions for two different pressures, 1.5 and 8 Pa. The relative densities of the various ions have been found to vary markedly between these pressures over the range of mixture proportions sampled. The kinetic model has provided a clear picture of the chemistry underlying the observed ion distributions and has helped identify the main sources and sinks of the major plasma ions (Ar⁺, ArH⁺ and H₃⁺). The results are discussed and whenever possible compared to previous works.

2. Experimental

The experimental set-up for the present studies has been described in previous works.^{15, 40-42} It consists of a grounded cylindrical stainless steel vessel (10 cm diameter, 34 cm length) that constitutes the cathode, and a central anode. The chamber can be pumped to a background pressure of 10^{-4} Pa with a 300 l s^{-1} turbomolecular pump, backed by a dry mechanical pump. The chamber walls have different ports for connection of gas inlets, diagnostics tools, observation windows, and pressure gauges. The chamber pressure was controlled by balancing the flow of the precursor gases with needle valves at the entrance and a butterfly valve at the exit of the reactor. The position of the butterfly valve was kept fixed during the experiments. Two discharge pressures 1.5 Pa and 8 Pa were investigated. For each pressure, the whole range of H_2 fractions was sampled. The plasma current was kept fixed at a value of 150 mA for all the experiments. The supply voltages were in the 300-400 V range, which correspond to discharge powers of 45-60 W. An electron gun with a tungsten wire operating at 2A and $-2000 \text{ V}_{\text{dc}}$ was used to initiate the discharge, and then switched off.

A plasma monitor (PM), based in a quadrupole mass spectrometer, with ion energy resolution, was employed to detect the plasma ions. The PM was installed in a differentially pumped chamber connected to the reactor through a $100 \mu\text{m}$ diaphragm. During operation, the pressure in the detection chamber was kept in the 10^{-5} Pa range by a 150 l s^{-1} turbomolecular pump backed by a dry pump. The same chamber contained a quadrupole mass spectrometer that was used to monitor the composition of the discharge precursor mixture in the reactor vessel.

Ion fluxes were calculated by integrating the ion energy distributions recorded by the PM for each individual ion. For the discharge pressures used in our experiments, the ion energy distributions measured at the cathode were in general narrow, with a peak close to the value of the cathode-anode potential, which indicates that for the comparatively large energies of the ions reaching the cathode, the plasma sheath is only mildly collisional for most species, i.e., the number of effective collisions is low and should not distort appreciably the ion fluxes between plasma and cathode. Appreciable effects of sheath collisions are only found for ions susceptible of undergoing symmetric charge exchange with the dominant neutrals (Ar^+ and H_2^+). This process, characterized by large cross-sections, leads to the appearance of a low-energy tail that grows at the expense of the narrow peak with increasing pressure,⁴³ but should not lead to a significant reduction of the measured flux for these ions. For our typical sheath

potentials (up to a few hundred eV), asymmetric charge exchange between Ar^+ and H_2 could also take place¹⁵ to a lesser extent, but for the present overall results this process should only play a minor role. The sensitivity of the PM to the masses of the different ions was calibrated with the noble gases He, Ne, and Ar. To this aim, the PM was used in the neutral detection mode (i.e. with the electron bombardment ionizer) and the signals of He, Ne and Ar were compared to the corrected readings of a Bayard-Alpert gauge located in the same chamber. This calibrated sensitivity corresponds to the whole ion detection system (energy analyzer, mass filter and multiplier). Most measurements were performed with a multiplier voltage of 3200 V and the relative detection sensitivity for a given singly charged ion of mass, m_i , was found to be proportional to $\sim m_i^{-0.22}$. Some of the experiments carried out with this multiplier voltage led to signal saturation (more than 2×10^6 counts s^{-1}) and it was necessary to perform the measurements with a multiplier voltage of 2800 V. In this case, the relative ion-mass sensitivity was $\sim m_i^{-0.71}$. The density of a given ion in the plasma glow was derived by multiplying the measured ion flux at the cathode by a factor $(m_i/q_i)^{0.5}$ to correct for the dependence of the flow velocity on the ion mass. We have not considered a dependence of the PM sensitivity on the incoming ion energy, assuming that it is a small source of error, since our energy distributions are predominantly narrow.

Electron mean temperatures, T_e , and densities, N_e , were measured with a double Langmuir probe built in our laboratory, under the assumptions of collision free probe sheath and orbital limited motion.⁴⁴ To estimate total charge densities from the characteristic curves of the Langmuir probe, a mean ion mass was used in each case, weighted according to the ion density distributions deduced from the PM measurements. Note that the derivation of a T_e from the double Langmuir probe measurements implies the assumption of a Maxwellian electron energy distribution function.⁴⁵

3. Kinetic model

For the analysis of the experimental measurements, we have used a simple zero-order kinetic model developed in our group, which is briefly described here. More detailed accounts can be found in refs.^{15, 41} The model is based on the numerical integration of a set of coupled differential equations accounting for the time evolution of

the various chemical species from the discharge ignition to the attainment of the steady state. It uses as input parameters the experimental partial pressures and flows of the precursor gases and also the electronic temperatures, T_e , and densities, N_e , which are assumed to be homogeneous throughout the plasma (negative glow) volume. It is further assumed that the ion temperature in the glow, T_{ion} , is similar to the gas temperature ($T_{ion} \approx 300 - 400$ K), analogously to what was found in previous spectroscopic studies of dc hollow cathode discharges.^{39, 46} The concentration of the various plasma species is assumed to be controlled by the set of homogeneous and heterogeneous reactions listed in the first column of Tables 1 and 2. General comments on these processes can be found in our previous work,¹⁵ where basically the same set of reactions was employed (see below). Rate coefficients for collision processes with Maxwellian electrons are listed in the second column of Table 1 with indication of their sources. In general, these values have been derived from cross section data using the expression $k = \langle \sigma v \rangle$, where σ is the cross section for the process of interest and v the relative velocity of the colliding partners.

Arrhenius-like functions or polynomials are used to express the dependence of these rate coefficients on T_e . Rate coefficients for ion-molecule reactions, also listed in the first column of Table 1, have been mostly taken from the compilation of Anicich.³² For reaction 18 ($H_3^+ + Ar$), an alternative much smaller rate constant from the tables of Albritton⁴⁷ has also been considered. The meaning of the two values is discussed at length in the next section. Throughout the text, reactions are referred to using the numbers of this table. It is well known that in hollow cathode discharges there is a high energy component in the electron energy distribution that results from secondary electron emission by the cathode, which is responsible for the presence of Ar^{2+} ions in our plasmas. In the third column of Table 1 we have included a series of rate coefficients for high energy electrons (~ 50 - 300 eV) derived also from cross section data (see ref 15 for details). The amount of high energy electrons within this energy range is very small. Specifically, for the present study we have used fractions of 3×10^{-4} and 3×10^{-6} high energy electrons for the 1.5 and 8 Pa discharges, respectively, that are enough to justify the observed Ar^{2+} density. These minute amounts of high energy electrons are unrelated to the Maxwellian electron energy distributions underlying the Langmuir probes measurements. In any case, with the densities assumed here these high energy

electrons would be undetectable by the probes and play no appreciable role in the global kinetics.

Metastable argon atoms (Ar^*) in $4s^3P_2$ and $4s^3P_0$ states, formed by electron impact, were not included in our previous work⁴¹ but have been incorporated here, since they can contribute to the formation of atomic hydrogen through the reaction $\text{Ar}^* + \text{H}_2 \rightarrow \text{Ar} + \text{H} + \text{H}$ (reaction 23). They can also lead to the formation of Ar^+ through Penning ionization (reaction 24). Ar^* de-excitation at the wall is also included (see Tables 1 and 2). The calculations show that the highest concentrations of Ar^* are similar to the electron densities, and that their influence in the global chemistry of the discharge is very small: H densities increase just by 2% in the most favorable cases and the changes in the other species are negligible.

Negative ions and excited states of H_2 are not contemplated in the kinetic model. Negative H^- ions can be formed in hydrogen plasmas and, in fact, there is a great interest in the development of sources of H^- based on different kinds of hydrogen discharges.^{48, 49} However, the production of this ion, usually through dissociative electron attachment to H_2 molecules, requires molecules in highly excited vibrational levels (especially $v \geq 4$).⁵⁰ In our previous study of emission spectroscopy of pure H_2 in conjunction with a collisional radiative model,⁴¹ it was shown that the H_2 vibrational populations in our plasmas are concentrated in the lowest levels and can be roughly described by a vibrational temperature of ~ 3000 K. The population of $\text{H}_2(v \geq 1)$ is $\sim 12\%$ and that of $\text{H}_2(v=4)$ of only $\sim 0.05\%$. Under these conditions, we do not expect the dissociative attachment channel to be relevant. Estimates based on model calculations and photodetachment measurements⁵⁰ indicate that the concentration of H^- in a hollow cathode discharge of hydrogen and neon is orders of magnitude lower than that of electrons. Consequently, we have assumed that electrons are the only negative charge carriers in our plasmas. Likewise, given the high threshold for electron impact dissociation of H_2 (~ 11 eV) as compared with the first vibrational quantum of H_2 (~ 0.5 eV), we do not expect a significant contribution of vibrationally excited molecules, $\text{H}_2(v)$, to the global electron impact dissociation of H_2 . The decrease in population with growing v is far more important than the increase in the rate coefficient due to the lower energy threshold. Recent model simulations of RF discharges have variously considered H^- and $\text{H}_2(v)$. Hjartarson et al.¹⁴ included both vibrational excitation and negative ions in their calculations. In contrast, Sode et al.¹⁷ did not include them and obtained a reasonable agreement between their results and those of Hjartarson et al.¹⁴ regarding the

ion chemistry. Sode et al.¹⁷ concluded that H^- and $H_2(v)$ are not crucial for the description of the positive ion densities, which is the subject of the present work.

The heterogeneous processes considered in the model are reduced to wall recombination of H atoms to form H_2 , and wall neutralization of the various positive ions (see Table 2). In analogy with refs.^{15, 41} the recombination of hydrogen atoms is accounted for with a single γ coefficient. A more refined treatment of H atom recombination at the wall, including adsorption and reaction steps, was introduced in a previous work by our group⁵¹ to describe H/D isotope exchange at the reactor walls. In the present study, with no isotope exchange and focused on the ionic chemistry in the gas phase, we have kept the simplified original model for the H_2 wall recycling. Atomic hydrogen concentrations are outside the scope of this work and were not measured. However, for the sake of completeness they have been estimated with the model. The major source of H atoms is the electron impact dissociation of H_2 (reaction 13). This is also the main mechanism for the production of H atoms in the rf plasma models mentioned above.^{13, 14, 17} The relative H concentrations, $[H]/([H]+[H_2]+[Ar])$, are always below 8% of the total concentration of neutral particles for all the conditions considered. In any case, H atoms have very little influence on the ionic chemistry, which is always dominated by collisions of ions with the major neutral species, Ar and H_2 .

4. Results and discussion

4.1 Electron temperatures and densities

The measured electron temperatures and densities are shown in Fig. 1 for the two pressures investigated, as well as the values used for the modeling (see below). For the 1.5 Pa discharge, the electron density shows a slow monotonic decline that becomes more pronounced for $[H_2]/([H_2]+[Ar]) > 0.8$. In the 8 Pa discharge, there is an abrupt drop in electron density for $[H_2]/([H_2]+[Ar]) < 0.1$. For larger ratios, N_e hardly decreases with growing H_2 content. In our experiments, where the discharge current is kept fixed in all cases, the evolution of the electron density, which equals the ion density due to the electroneutrality condition, is determined to a large extent by the ion composition in the plasma (see below). The flow of the heavier ions (Ar^+ , ArH^+) to the cathode is much slower than that of the hydrogenic species (mostly H_3^+). Consequently, in plasmas where heavy ions are predominant, a higher ion density is needed to maintain the same current as in plasmas dominated by light ions. Therefore the total ion

(and electron) density decreases with growing H_2 content. A qualitatively similar decrease was observed in the experiments with inductively coupled Ar/ H_2 plasmas.^{6, 13, 14, 16}

The measured electron temperatures are higher, as expected, for the lower pressure (1.5 Pa) discharge. For this pressure, within the experimental uncertainties, the T_e values oscillate around a constant value of ≈ 2.8 eV, regardless of the mixture proportion. This temperature is consistent with those of previous experiments by our group for $[H_2]/([H_2]+[Ar]) = 0.85$ hollow cathode discharges in a similar pressure range.¹⁵ For the 8 Pa discharge, T_e reaches a maximum value of 2.6 eV for H_2 fractions ~ 0.1 , but it lies between 2.2 and 1.7 eV over most of the relative concentration interval. Similar or somewhat higher electron temperatures are found for inductively coupled discharges at comparable pressures.^{13, 14, 17} In those rf plasmas, however, the electron temperature shows a smooth variation over a wide range of mixture proportions, but tends to increase appreciably for the highest H_2 fractions. This tendency is not observed in the Langmuir probe measurements for our hollow cathode discharges, which give similar values for the pure H_2 and pure Ar plasmas within experimental uncertainty. At present we have no explanation for this contrasting behavior.

4.2 Ion distributions

The relative ion concentrations determined in the experiments are displayed in Figs 2-5, together with model simulations. The absolute concentrations for a given ion can be readily derived by multiplying its relative concentration by the total ion density, which coincides with the electron density for the same pressure and mixture proportion (see Fig. 1). Figs. 2 and 3 represent the relative ion concentrations for 1.5 and 8 Pa in linear scale. The experimental values are shown in the middle panels. Note that for the two pressures and for all H_2 fractions, the distributions are dominated by Ar^+ , ArH^+ and H_3^+ but important changes can be observed between both panels: 1) a very marked displacement of the ArH^+ maximum towards the lowest H_2 fraction at the highest pressure, 2) a drastic reduction of the Ar^+ prevalence region and 3) a noticeable broadening of the H_3^+ dominance region. For a better understanding of these results, four model simulations have been carried out, two for each of the two discharge pressures studied. For each pressure, their respective T_e and N_e set of values have been used (see Fig. 1), and the only difference between the two simulations is the rate

coefficient for the reaction of H_3^+ with Ar (reaction 18), which may be strongly dependent on the internal excitation of the H_3^+ ion, as we shall discuss below. The recommended value from the compilation of Anicich³² ($3.65 \times 10^{-10} \text{ cm}^3 \text{ s}^{-1}$) is taken as the higher k_{18} (termed $^{\text{H}}k_{18}$ hereinafter) for the calculations. The corresponding results are displayed in the lower panels of Figs 2 and 3. As a lower value for k_{18} , we have taken the rate coefficient from the tables of Albritton⁴⁷ ($1 \times 10^{-11} \text{ cm}^3 \text{ s}^{-1}$, termed $^{\text{L}}k_{18}$ hereinafter) (see upper panels of Figs. 2 and 3). Figs. 4 and 5 represent the ion distributions for the two pressures using a logarithmic ordinate scale for a better appreciation of the minor ions: Ar^{2+} , H^+ and H_2 .

For the two pressures, the experimental Ar^+ density decreases monotonically with growing H_2 proportion, but the decrease is slower in the 1.5 Pa discharge (middle panel of Fig. 2). In this plasma, ArH^+ is the second ion in importance for H_2 fractions between 0.05 and 0.3 and becomes the major ion for ratios between 0.3 and 0.7. The relative concentration of H_3^+ grows monotonically with increasing H_2 content, surpasses that of Ar^+ for H_2 fractions ~ 0.4 , and becomes dominant for fractions larger than 0.7. In the 8 Pa discharge (middle panel of Fig. 3) the ion distribution is dominated by H_3^+ over most of the mixture range, ArH^+ prevails over a very narrow interval (0.005-0.03) of H_2 fractions, and Ar^+ is the major ion only when there is virtually no H_2 in the discharge.

For the 1.5 Pa discharge, the best agreement between measurements and simulations is obtained with $^{\text{H}}k_{18} = 3.65 \times 10^{-10} \text{ cm}^3 \text{ s}^{-1}$.³² With this rate constant, the model provides a good global description of the measured ion distributions. It accounts for the decrease of Ar^+ with increasing H_2 fraction, for the dominance of ArH^+ at intermediate H_2 fractions, where this ion concentrates 40% of the positive charge, and for the final prevalence of H_3^+ in the mixtures with the highest H_2 content. The calculations render well the crossing between the Ar^+ and the H_3^+ curves, although the predicted interval of ArH^+ prevalence is shifted slightly toward lower H_2 fractions. The model results with $^{\text{L}}k_{18} = 1 \times 10^{-11} \text{ cm}^3 \text{ s}^{-1}$,⁴⁷ are shown in the upper panel of Fig. 2. The agreement between measurements and calculations is now worse: the predicted ArH^+ is never clearly dominant and the crossing between the decreasing ArH^+ and the growing H_3^+ takes place at a lower H_2 fraction.

For the 8 Pa discharge, the application of the model with $^{\text{H}}k_{18}$ leads to the ion distributions depicted in the lower panel of Fig. 3. The agreement with experiment is

much worse here than in the previous case. The model predicts indeed a steeper decrease of the Ar^+ concentration than that of the 1.5 Pa discharge and a shifting of the ArH^+ maximum toward a lower H_2 fraction, but this maximum is too broad and the descent of the ArH^+ density too slow. The rise of the H_3^+ concentration is likewise too gradual as compared with the experimental data. The accordance between experiment and model improves significantly if ${}^L k_{18}$ is employed in the calculations. In this case, H_3^+ dominates largely the ion distributions over most of the H_2 fraction range, and ArH^+ exhibits a comparatively narrow maximum for a low (< 0.1) H_2 fraction. In spite of the described improvement, the variation in the main ion concentrations predicted by the model is still too smooth in comparison with the measurements.

The distribution of the minor ions in the two discharges can be better seen in the logarithmic representations of Figs. 4 and 5. In this case, for the sake of clarity, model simulations are restricted to those giving a better agreement with the measurements (i.e. with ${}^H k_{18}$ for 1.5 Pa and ${}^L k_{18}$ for 8 Pa). Overall, a better accordance is obtained for the 1.5 Pa discharge. The model predicts the expected increase in the relative weight of the minor hydrogenic ions, H^+ and H_2^+ , with growing H_2 proportion, although the concentration of H_2^+ is underestimated up to an order of magnitude. Finally, as commented on above, the small amount of Ar^{2+} observed in the measurements can be justified by assuming a very small fraction ($< 5 \times 10^{-4}$) of electrons with energies higher than 50 eV that would be undetectable by the Langmuir probes.

4.3 Key reaction mechanisms

The analysis of the results shows that just two key factors are responsible for the main differences between the distributions of the major plasma ions at the two discharge pressures studied: the electron temperature and the k_{18} value, closely related with the degree of vibrational excitation of H_3^+ . The effect of T_e can be appreciated in Fig 6. For any T_e value, the rate for electron impact ionization of Ar (k_{14}) is 6-7 times larger than that for H_2 (k_7), consequently, among the primary ions, Ar^+ will prevail over H_2^+ up to very high hydrogen fractions. A drop in electron temperature from 3 to 2 eV, similar to that observed upon increasing the discharge pressure from 1.5 to 8 Pa, results in an approximate 30-fold decrease of k_{14} and k_7 and, thus, in a much larger relative weight of ion-molecule chemistry vs electron impact ionization. This explains the steep descent in the Ar^+ density with growing H_2 ratio observed in the 8 Pa discharge. The primary Ar^+

ions generated by electron impact (reaction 14) are immediately transformed into ArH^+ through reaction 20 ($\text{Ar}^+ + \text{H}_2$), whose rate coefficient (k_{20}) is nearly 100 times larger than k_{14} at 2 eV. In the case of the 1.5 Pa discharge, the ratio between the same two coefficients is roughly a factor of four, which leads to a more gradual evolution of the concentrations of Ar^+ and ArH^+ . With a further increase in the proportion of H_2 , collisions of ArH^+ with hydrogen molecules (reaction 21) gain in importance and lead to the production of H_3^+ . Part of these H_3^+ ions can revert to ArH^+ through reaction 18. Reactions 17 and 10 can also contribute to the production of ArH^+ and H_3^+ respectively but, given the small density of H_2^+ ions in the plasmas considered, they play only a minor role.

The importance of internal energy effects in the equilibrium between the reactions 18 and 21, interconverting ArH^+ and H_3^+ , has been addressed in previous works.⁵²⁻⁵⁶ Reaction 21 leading from ArH^+ to H_3^+ is exothermic by about 0.55 eV.⁵⁵ Rate coefficient measurements for this reaction performed by various groups yield mostly large values $\approx (5-15) \times 10^{-10} \text{ cm}^3 \text{ s}^{-1}$, as expected for an exothermic ion-molecule reaction (see references in ref. ³²). The rate constant recommended by Anicich³² ($k_{21} = 6.3 \times 10^{-10} \text{ cm}^3 \text{ s}^{-1}$) and used in the present model is thus a reasonable choice. The reverse reaction (18), leading from H_3^+ to ArH^+ is endothermic by 0.55 eV. In this case the recommended value,³² $k_{18} = 3.65 \times 10^{-10} \text{ cm}^3 \text{ s}^{-1}$ ($^{\text{H}}k_{18}$), corresponds to the ion-cyclotron resonance (ICR) measurements of Bowers and Elleman⁵⁷ and is about 60% of the recommended value for reaction 21, but later measurements by Roche et al.⁵⁸ indicated that k_{18} should be at most an order of magnitude smaller than k_{21} . Taking this experiment into account, Albritton⁴⁷ gave an upper limit of $k_{18} = 1 \times 10^{-11} \text{ cm}^3 \text{ s}^{-1}$ ($^{\text{L}}k_{18}$).

We attribute the large discrepancy between the k_{18} values estimated by the two groups to the different experimental methods used. In the experiments of Bowers and Elleman⁵⁷ the source of H_3^+ is the reaction of H_2^+ ions with H_2 molecules (reaction 10). As noted by the authors, the high exoergicity of this reaction⁵⁹ (1.72 eV) could be largely stored as vibrational energy of the nascent H_3^+ , which would not be significantly deactivated by collisions in the low pressure ICR measurements. The large rate coefficient determined in this experiment would thus pertain to the reaction of $[\text{H}_3^+]^* + \text{Ar}$, which becomes exothermic for an internal excitation energy higher than 0.55 eV. In contrast, the measurements of Roche et al.,⁵⁸ setting a much smaller upper limit for k_{18} ,

were performed in a flow reactor with a much more efficient collisional relaxation of the H_3^+ reactant, and correspond most probably to an endothermic $\text{H}_3^+ + \text{Ar}$ reaction.

Experimental and theoretical works^{52, 53, 60-62} indicate that the H_3^+ ions produced in reaction 10, which is favored in plasmas with a very large hydrogen fraction, are highly vibrationally excited and that this excitation can be effectively quenched through collisions with H_2 , but there is no unanimity on the actual relaxation efficiency. In plasmas with Ar and H_2 , reaction 21 can become the main source of H_3^+ . If the reaction takes place with ground state ArH^+ , the resulting H_3^+ ions will not have enough vibrational excitation to revert the process through reaction 18 and will remain as H_3^+ . However, if ArH^+ is vibrationally excited, it can transfer part of its excitation to the H_3^+ product, which could then react back with Ar displacing the equilibrium of reactions 18 and 21 toward the reconstruction of ArH^+ .⁵⁶ The main source of ArH^+ in Ar containing plasmas is the reaction of Ar^+ with H_2 (reaction 20). These reactions have been studied, both experimentally and theoretically (see for instance refs.^{63, 64} and references therein), but still many aspects of its state specific dynamics and, in particular, of the energy partitioning among the nascent product molecules are not known with precision. Trajectory calculations by Chapman⁶⁵ on a semiempirical potential energy surface indicate that a large fraction of the exothermicity of reactions 17 and 20 should appear initially as vibrational excitation of ArH^+ . In the presence of sufficient Ar, the internal excitation of ArH^+ could be quenched through the process:⁵⁴ $(\text{ArH}^+)^* + \text{Ar} \rightarrow \text{ArH}^+ + \text{Ar}^*$. Electron impact could also provide a mechanism for the vibrational excitation of H_3^+ in plasmas.⁶⁶

To sum up, although the degree of vibrational excitation of the nascent ArH^+ and H_3^+ and the relevance of the likely relaxation pathways is not precisely known, it is reasonable to expect that collisional relaxation and, in particular, that of the sensitive H_3^+ ion, will be appreciably higher in the 8 Pa experiments than in those at 1.5 Pa. To simulate in a simple way this effect, we have taken the rate coefficient of Albritton (${}^1k_{18} = 1 \times 10^{-11} \text{ cm}^3 \text{ s}^{-1}$) for the endothermic process with vibrationally relaxed H_3^+ . Comparison of the upper and lower panels of Figs 2 and 3 shows that the influence of introducing ${}^1k_{18}$ in the kinetic model is much more marked in the ion distributions of the 8 Pa discharge, which are now in reasonable accordance with experiment. Further tests with the kinetic model show that a much better agreement is obtained with a lower electron temperature (1.7-1.8 eV) for the lower H_2 fractions. Nevertheless, for

consistency, we present only the simulations corresponding to electron temperatures within the estimated uncertainty of the probe measurements. We note however that the double Langmuir probes used in our measurements provide only an estimate of T_e under the assumption of Maxwellian electron energy distributions and are not sensitive to the actual shape of the high energy tail of the distribution. A selective depletion of electrons in this high energy tail would go unnoticed in the probe measurements, but would correspond to an effective lower electron temperature for the kinetics.

The increase in the discharge pressure has thus a two-fold effect on the concentration of ArH^+ . On the one hand, it lowers the electron temperature decreasing the rate of formation of Ar^+ , the main ArH^+ precursor. On the other hand, it can lead to the quenching of the internal excitation of H_3^+ , diminishing markedly the rate of reaction 18, which is also a source of ArH^+ . As a consequence, the prevalence of ArH^+ is restricted to a very narrow range of mixture proportions with very little H_2 . This behavior explains also the puzzling results of the many spectroscopy experiments mentioned above,³³⁻³⁹ where the best ArH^+ signals were found with little or no H_2 at all in the precursor gas. The conditions in these experiments, usually performed with comparatively high discharge pressures, are qualitatively similar to the present results for the 8 Pa discharge, where the optimal condition for ArH^+ is obtained with just traces (less than 3%) of H_2 . Furthermore, we have observed by mass spectrometry in a different hollow cathode discharge cell,³⁹ using 40 Pa of pure Ar as precursor, that a tiny amount (~ 0.2 Pa) of H_2 is ejected from the cathode when the discharge is on. This small amount of H_2 provided an adequate concentration of ArH^+ for spectroscopic measurements.

4.4 Main formation and loss rates

The calculated steady state rates for the main production and loss mechanisms of the three major ions are represented in figures 7 and 8 for the 1.5 and 8 Pa discharges respectively. Only the results corresponding to the k_{18} value that gives a best agreement with the measured data are displayed for each pressure. Fig. 7 shows that in the 1.5 Pa discharge Ar^+ is produced by electron impact ionization of Ar atoms and is destroyed through neutralization at the wall or through reaction with H_2 (reaction 20), which becomes the dominant destruction mechanism for H_2 fractions higher than 0.2. The main generation mechanisms of ArH^+ are reactions 18 and 20. Overall, reaction 20

dominates but, for H_2 fractions higher than 0.6, reaction 18 becomes slightly preponderant. ArH^+ ions are mainly lost in reaction with H_2 (reaction 21) although for H_2 lower than 0.2, wall neutralization is the main loss mechanism. H_3^+ ions are essentially produced in collisions of ArH^+ with H_2 over the whole mixture proportion range. Reaction 10 ($\text{H}_2^+ + \text{H}_2$), which is the predominant H_3^+ formation mechanism in many hydrogen plasmas, plays here a minor role. The H_3^+ ions are destroyed in nearly equal amounts in collisions with Ar (reaction 18) and through wall neutralization. Fig. 8 shows the important changes in the relative weight of the various production and destruction mechanisms when the discharge pressure is raised to 8 Pa. The ionization rate of Ar shows here a maximum for H_2 fractions lower than 0.2, which corresponds to the small maximum in the electron temperature depicted in Fig. 1 (upper-right panel). Reaction 20 becomes now the main mechanism of Ar^+ loss for H_2 fractions larger than just 0.05. The ArH^+ ion is largely formed through reaction 20 and lost in collisions with H_2 (reaction 21) over the whole mixture fraction range. In contrast with the results for the 1.5 Pa discharge, reaction 18 ($\text{H}_3^+ + \text{Ar}$) and flow to the wall play just a small role in the production and destruction of ArH^+ respectively. The H_3^+ ion is mostly formed in collisions of ArH^+ with H_2 (reaction 21) and is mainly lost through wall neutralization and to a minor extent through reaction 18.

4.5 Comparison with previous works

As mentioned in the introduction, there are some recent studies^{13, 14, 17} on the ion chemistry in Ar/ H_2 inductively coupled rf discharges of variable mixture proportions and for pressures similar to those of the present work. Due to the different properties of the discharges, only an approximate comparison of those results with our work is possible, but it could still be meaningful considering that ionic chemistry is determined to a large extent by the electron temperature (which is closely related to the pressure) and by the gas composition. In comparison with the present work, the model of Kimura and Kasugai¹³ underestimates ArH^+ production. It does not include reactions 18 and 17 (which produce ArH^+) and takes a value of $1.5 \times 10^{-9} \text{ cm}^3 \text{ s}^{-1}$ (twice the value used in our model) for the rate coefficient of reaction 21 that destroys ArH^+ to form H_3^+ . Their calculated ion distributions at 2.8 and 8 Pa are always dominated either by Ar^+ or by H_3^+ , with ArH^+ being only the third ion in importance over the 0-50% range of H_2 fractions studied. The model of Hjartarson et al.¹⁴ leads also to too low ArH^+ concentrations as compared with this work. The calculations performed for 1.33 Pa

yield ion distributions that are always dominated either by Ar^+ or by H_3^+ . The density of ArH^+ is always less than half of that of the dominant ion. These authors used the same value as Kimura and Kasugai for the rate coefficient of reaction 21 (a factor two larger than ours, as just noted) and took $k_{18} = 1 \times 10^{-11} \text{ cm}^3 \text{ s}^{-1}$, which we found to be adequate for our 8 Pa measurements, but was too low for the 1.5 Pa experiments. Neither Kimura and Kasugai, nor Hjartarson et al. compared their model ion distributions with experimental data.

The detailed study of Sode et al.¹⁷ provided both experimental ion distributions and model simulations for a discharge pressure of 1 Pa ($T_e = 3\text{-}4 \text{ eV}$). The model calculations covered the whole range of mixture proportions and the measurements were performed for the 0.28-1 H_2 fraction range. The experimental distributions were dominated by ArH^+ , with Ar^+ being the second ion in importance. The measured H_3^+ densities were always very low, even for the highest H_2 fractions. In their model, the authors used the rate coefficients recommended by Anicich³² for the relevant ArH^+ reactions. Specifically, they took $k_{18} = 3.65 \times 10^{-10} \text{ cm}^3 \text{ s}^{-1}$, one of the values used in the present work. The simulations¹⁷ led to appreciably higher densities of H_3^+ and lower densities of ArH^+ than their experiments. The reasons for the disagreement are not clear. Sode et al.¹⁷ noted that $k_{21} \sim 0$ would bring the simulations in much better accordance with their measurements and questioned the reliability of the recommended value³² ($6.3 \times 10^{-10} \text{ cm}^3 \text{ s}^{-1}$). This conclusion is however not warranted. As indicated above, k_{21} has been measured by several groups^{32, 55, 67} using different methods and consistently high values have been derived. In our lower pressure experiments, carried out for conditions of T_e and discharge pressure comparable to those of Sode et al.,¹⁷ the simulations using the recommended rate coefficients lead to a reasonably good agreement with the measurements (see the two lower panels of Fig 2). Moreover, it is worth noting that the agreement between our experimental data and the model simulations of Sode et al.¹⁷ is not too bad.

In the diffuse interstellar cloud model used by Schilke et al.,² ArH^+ is essentially produced in collisions of H_2 with Ar^+ (reaction 20), which is in turn generated in the ionization of Ar atoms by cosmic rays or X-rays. Once formed, ArH^+ is mostly lost in proton transfer collisions with O atoms and with H_2 molecules (reaction 21). The authors remark that the unusually low rates for photodissociation and electron impact dissociative recombination of ArH^+ enhance the survival of the ion in the diffuse ISM.

For molecular hydrogen fractions, $2[\text{H}_2]/[\text{H}]$, larger than 10^4 , collisions with H_2 (reaction 21) are by far the preponderant mechanism for ArH^+ destruction. As graphically expressed by Schilke et al.,² ArH^+ is a molecule that paradoxically abhors molecular clouds. Reactions 20 and 21 are also the main production and destruction mechanisms of ArH^+ in most of the plasmas studied in the present work and the abhorrence of ArH^+ for H_2 is clearly seen in the ion distributions of our 8 Pa discharge (middle panel of Fig 3). Reaction 18 ($\text{H}_3^+ + \text{Ar}$), which is found to be an important source of ArH^+ in many plasmas, such as the low pressure discharges in this work, is also included in the astrochemical model of Schilke et al., but with a very low rate coefficient ($8 \times 10^{-10} \exp(-6400 \text{ K/T}) \text{ cm}^3 \text{ s}^{-1}$), which seems appropriate for the vibrationally relaxed H_3^+ expected in diffuse cloud sources. In other environments like the knots and filaments of the Crab Nebula, where ArH^+ was first identified,¹ internal excitation of H_3^+ by warm electrons may increase the relevance of this reaction.

5. Summary and Conclusions

The ion chemistry in cold Ar/H_2 plasmas has been investigated in hollow cathode discharges. The experiments have been carried out for total pressures of 1.5 and 8 Pa, and spanning the whole range of $[\text{H}_2]/([\text{H}_2] + [\text{Ar}])$ ratios for each of the two pressures. A simple kinetic model, which takes the measured electron temperatures and densities as input parameters, has been used to rationalize the experimental data and to identify the main reaction mechanisms.

Three species, Ar^+ , ArH^+ and H_3^+ , have been always found to dominate the measured ion distributions, but their relative densities vary markedly with pressure and with the Ar/H_2 mixture proportion. Special attention has been paid to the chemistry of ArH^+ . This ion was prevalent in the range $0.3 < [\text{H}_2]/([\text{H}_2] + [\text{Ar}]) < 0.7$ in the 1.5 Pa discharge, but its predominance became restricted to $[\text{H}_2]/([\text{H}_2] + [\text{Ar}]) < 0.4$ in the 8 Pa plasma.

The kinetic model reveals two key factors for the ion chemistry in these plasmas: Electron temperature and the equilibrium of the process $\text{H}_3^+ + \text{Ar} \rightleftharpoons \text{ArH}^+ + \text{H}_2$. Electron temperature, which is basically a function of plasma pressure, determines the rates of formation of the primary plasma ions (Ar^+ and H_2^+) that start the ion-molecule chemistry. The rate of formation of Ar^+ is always 6-7 times larger than that of H_2^+ , and Ar^+ is the dominant primary ion up to very high H_2 fractions. Electron temperature

decreases roughly from 3 to 2 eV when the discharge pressure is increased from 1.5 to 8 Pa. As a result, the ionization rates of Ar and H₂ drop by a factor of ≈ 30 and the ions produced through ion-molecule chemistry (ArH⁺ and H₃⁺) gain in importance as compared with those directly formed by electron impact. Collisions of Ar⁺ with H₂ lead to an efficient production of ArH⁺. This ion can then give rise to H₃⁺ in subsequent collisions with H₂. The ratio between ArH⁺ and H₃⁺ depends strongly on the rate of the H₃⁺ + Ar \rightarrow ArH⁺ + H₂ reaction, which is endothermic and should be slow for ground state reactants, but becomes exothermic and should be much faster for an internal excitation of H₃⁺ larger than 0.55 eV.

Our experiments and model simulations strongly suggest that H₃⁺ has an appreciable degree of internal excitation in the lower pressure (1.5 Pa) plasma and that this excitation is largely quenched in the higher pressure (8 Pa) discharge. This interpretation reconciles conflicting literature values for the rate coefficient of the H₃⁺ + Ar reaction and leads to a reasonably good agreement between our measurements and model simulations over the whole range of conditions sampled. On the other hand, the results corroborate the comparatively large ($> 5 \times 10^{-10} \text{ cm}^3 \text{ s}^{-1}$) rate coefficient for the exothermic reaction ArH⁺ + H₂ \rightarrow Ar + H₃⁺, currently accepted in the literature, but questioned in a recent work. In the absence of a mechanism that regenerates ArH⁺ like the mentioned [H₃⁺]^{*} + Ar reaction, the argonium ion is efficiently removed in H₂ containing media, even if H₂ is present in very small amounts. This behavior, which is exemplified in our higher pressure discharge, was also reported in previous spectroscopic investigations carried out in comparable discharge cells, and is also displayed by the astrochemical models applied to the recent observations of ArH⁺ in the interstellar medium.

The results of this study invite further theoretical and experimental work on the detailed state-specific dynamics of the processes involved in the production, destruction, excitation and quenching of ArH⁺ and H₃⁺.

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Table 1 Homogeneous reactions and rate coefficients, k (cm^3s^{-1}). k^A : Rate coefficients for Maxwellian electrons at T_e (eV). k^B : Rate coefficients for high energy electrons (> 50 eV, see text). Two alternative values are given for the rate coefficient of reaction ${}^Hk_{18}$ and ${}^Lk_{18}$. The origin of these coefficients and their influence in the model simulations is discussed in the text. Numbers in parentheses indicate the references used as sources for the corresponding rate coefficients.

Homogeneous Reactions	k^A	k^B
1.- $\text{H} + \text{e} \rightarrow \text{H}^+ + 2\text{e}$	$6.50 \times 10^{-9} \times T_e^{0.49} \times e^{-12.89/T_e}$ (41)	4.2×10^{-8} (15)
2.- $\text{H}_2 + \text{e} \rightarrow \text{H}^+ + \text{H} + 2\text{e}$	$3.00 \times 10^{-8} \times T_e^{0.44} \times e^{-37.73/T_e}$ (41)	4.5×10^{-9} (15)
3.- $\text{H}_2^+ + \text{e} \rightarrow \text{H}^+ + \text{H} + \text{e}$	$1.07 \times 10^{-7} \times T_e^{0.049} \times e^{-9.69/T_e}$ (41)	
4.- $\text{H}_2^+ + \text{e} \rightarrow \text{H}^+ + \text{H}^+ + 2\text{e}$	$2.12 \times 10^{-9} \times T_e^{0.31} \times e^{-23.30/T_e}$ (41)	
5.- $\text{H}_2^+ + \text{H} \rightarrow \text{H}_2 + \text{H}^+$	6.4×10^{-10} (32)	
6.- $\text{H}_2 + \text{H}^+ \rightarrow \text{H}_2^+ + \text{H}$	1.19×10^{-22} (41)	
7.- $\text{H}_2 + \text{e} \rightarrow \text{H}_2^+ + 2\text{e}$	$3.12 \times 10^{-8} \times T_e^{0.17} \times e^{-20.08/T_e}$ (41)	5.0×10^{-8} (15)
8.- $\text{H}_3^+ + \text{e} \rightarrow \text{H}_2^+ + \text{H} + \text{e}$	$4.85 \times 10^{-7} \times T_e^{-0.05} \times e^{-19.17/T_e}$ (41)	
9.- $\text{H}_2^+ + \text{e} \rightarrow \text{H}^* + \text{H}$	$a + b \times T_e + c \times T_e^2 + d \times T_e^3 + e \times T_e^4$ (*) (41)	
10.- $\text{H}_2^+ + \text{H}_2 \rightarrow \text{H}_3^+ + \text{H}$	2.0×10^{-9} (32)	
11.- $\text{H}_3^+ + \text{e} \rightarrow 3\text{H}$	$0.5 \times K(**)$ (41)	
12.- $\text{H}_3^+ + \text{e} \rightarrow \text{H}_2 + \text{H}$	$0.5 \times K(**)$ (41)	
13.- $\text{H}_2 + \text{e} \rightarrow 2\text{H} + \text{e}$	$1.75 \times 10^{-7} \times T_e^{-1.24} \times e^{-12.59/T_e}$ (41)	1×10^{-8} (15)
14.- $\text{Ar} + \text{e} \rightarrow \text{Ar}^+ + 2\text{e}$	$2.53 \times 10^{-8} \times T_e^{0.5} \times e^{-16.3/T_e}$ (15)	1.6×10^{-7} (15)
15.- $\text{Ar} + \text{e} \rightarrow \text{Ar}^{2+} + 3\text{e}$	$2.58 \times 10^{-9} \times T_e^{0.5} \times e^{-47/T_e}$ (15)	1.1×10^{-8} (15)
16.- $\text{Ar}^+ + \text{e} \rightarrow \text{Ar}^{2+} + 2\text{e}$	$1.9 \times 10^{-8} \times T_e^{0.5} \times e^{-27.7/T_e}$ (15)	
17.- $\text{H}_2^+ + \text{Ar} \rightarrow \text{ArH}^+ + \text{H}$	2.1×10^{-9} (32)	
18.- $\text{H}_3^+ + \text{Ar} \rightarrow \text{ArH}^+ + \text{H}_2$	${}^Hk_{18} = 3.65 \times 10^{-10}$ (32) ${}^Lk_{18} = 1 \times 10^{-11}$ (47)	
19.- $\text{Ar}^+ + \text{H}_2 \rightarrow \text{H}_2^+ + \text{Ar}$	$0.02 \times 8.9 \times 10^{-10}$ (32)	
20.- $\text{Ar}^+ + \text{H}_2 \rightarrow \text{ArH}^+ + \text{H}$	$0.98 \times 8.9 \times 10^{-10}$ (32)	
21.- $\text{ArH}^+ + \text{H}_2 \rightarrow \text{H}_3^+ + \text{Ar}$	6.3×10^{-10} (32)	
22.- $\text{Ar} + \text{e} \rightarrow \text{Ar}^* + \text{e}$	$9.90 \times 10^{-10} \times T_e^{-0.08} \times e^{-11.72/T_e}$ (14)	2.4×10^{-8} (10)
23.- $\text{Ar}^* + \text{H}_2 \rightarrow 2\text{H} + \text{Ar}$	7.0×10^{-11} (10)	
24.- $\text{Ar}^* + \text{Ar}^* \rightarrow \text{Ar} + \text{Ar}^+ + \text{e}$	6.4×10^{-10} (10)	

$$(*) a = 7.51 \times 10^{-9}, b = -1.12 \times 10^{-9}, c = 1.03 \times 10^{-10}, d = -4.15 \times 10^{-12}, e = 5.86 \times 10^{-14}$$

$$(**) K = 8.39 \times 10^{-9} + 3.02 \times 10^{-9} \times T_e - 3.80 \times 10^{-10} \times T_e^2 + 1.31 \times 10^{-11} \times T_e^3 + 2.42 \times 10^{-13} \times T_e^4 - 2.30 \times 10^{-14} \times T_e^5 + 3.55 \times 10^{-16} \times T_e^6$$

Table 2 Heterogeneous processes

Heterogeneous Reactions	Wall Reaction Coefficients
1.- $H + \text{Wall} \rightarrow H_2$	$\gamma = 0.03$
2.- $H^+ + \text{Wall} \rightarrow H$	$\gamma = 1$
3.- $H_2^+ + \text{Wall} \rightarrow H_2$	$\gamma = 1$
4.- $H_3^+ + \text{Wall} \rightarrow H_2 + H$	$\gamma = 1$
5.- $Ar^+ + \text{Wall} \rightarrow Ar$	$\gamma = 1$
6.- $ArH^+ + \text{Wall} \rightarrow Ar + H$	$\gamma = 1$
7.- $Ar^{2+} + \text{Wall} \rightarrow Ar$	$\gamma = 1$
8.- $Ar^* + \text{Wall} \rightarrow Ar$	$\gamma = 1$

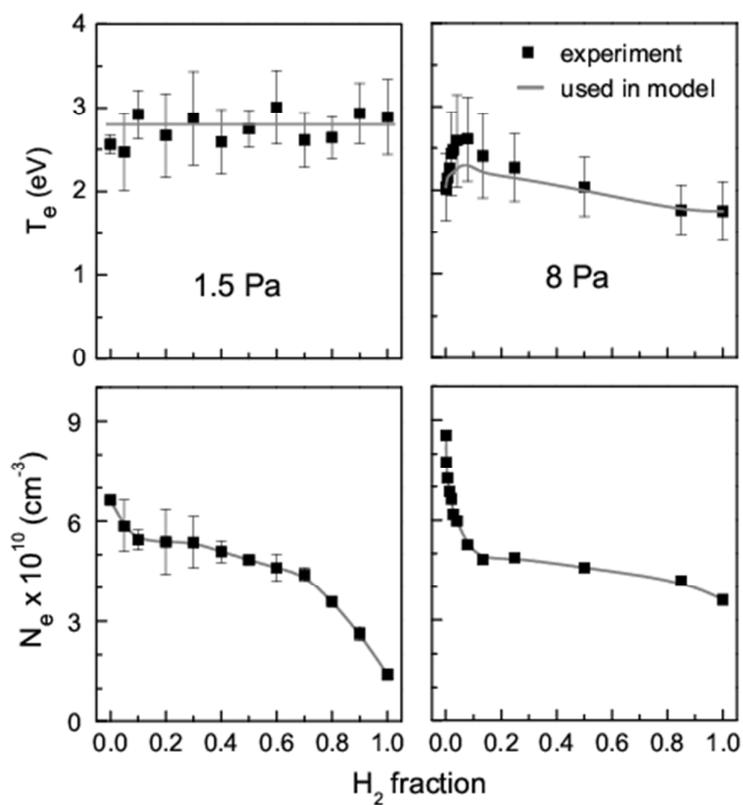


Fig. 1 Evolution of the electron temperature (upper panels) and density (lower panels) as a function of the H_2 fraction for the 1.5 Pa (left) and the 8 Pa (right) discharge. Solid symbols: experimental values. Lines: values used in the kinetic model.

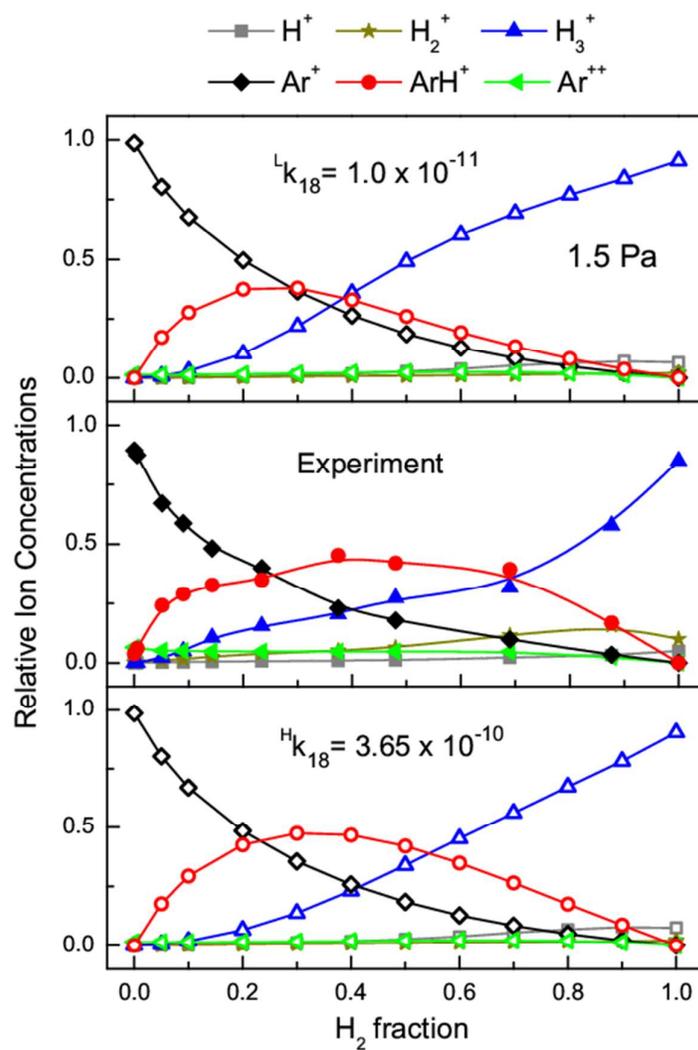


Fig. 2 Relative ion distributions as a function of the H_2 fraction for the 1.5 Pa discharge. Middle panel: Experimental measurements. Lower panel: Model simulation with $^{\text{H}}k_{18}$. Upper panel: Model simulations with $^{\text{L}}k_{18}$ (see text).

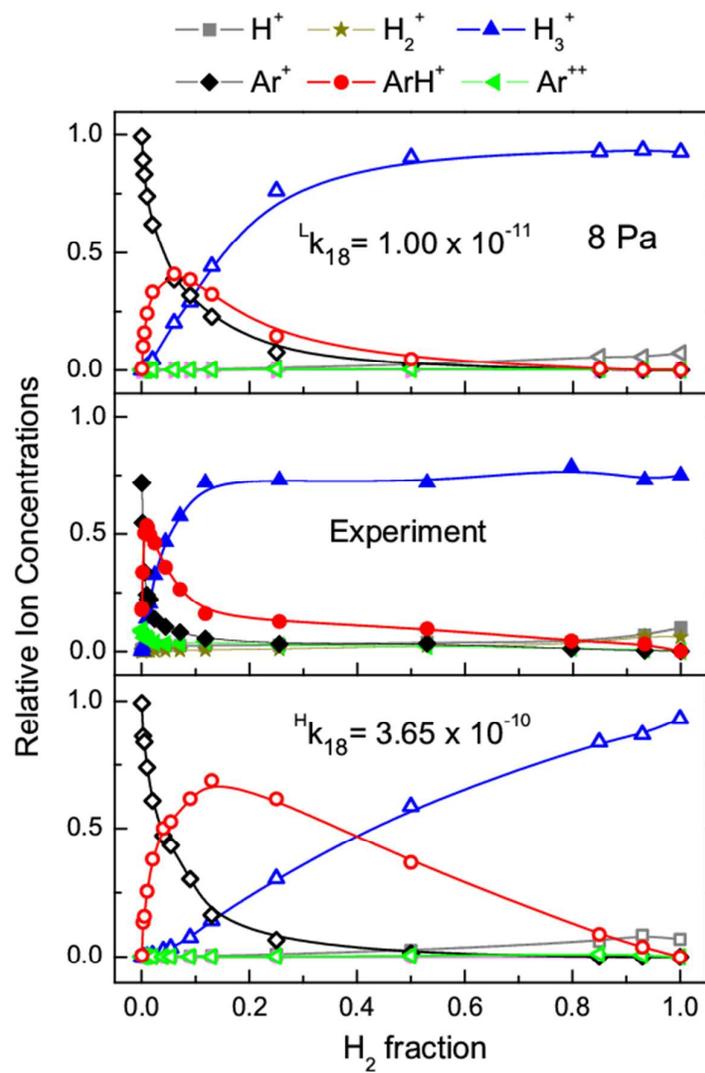


Fig. 3 Same as Figure 2, but for the 8 Pa discharge.

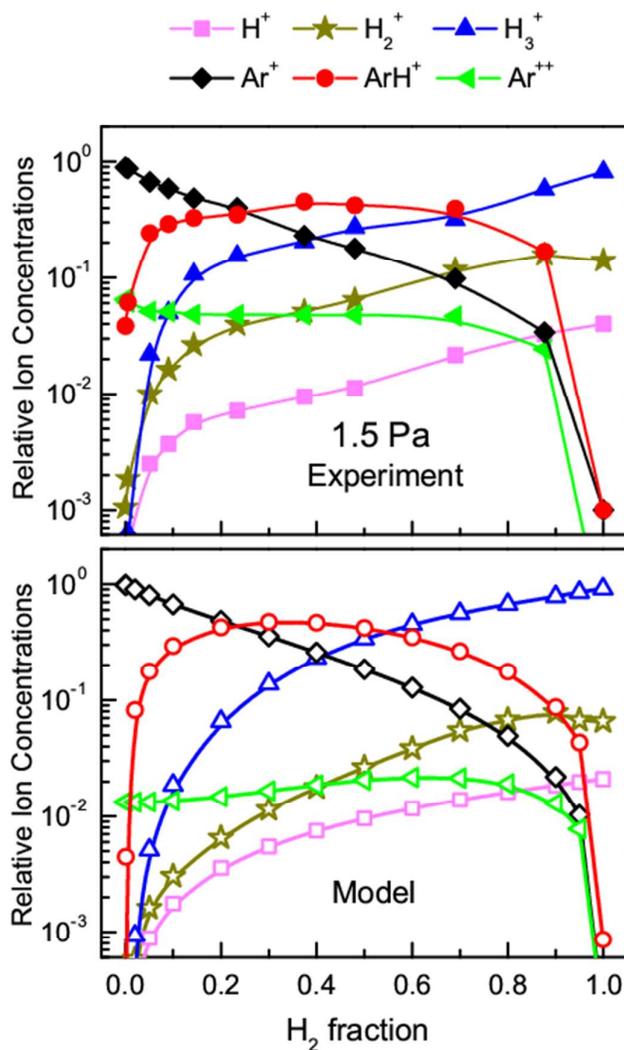


Fig. 4 Relative ion distributions for the 1.5 Pa discharge. Upper panel: experimental measurements. Lower panel: model simulation with ${}^{\text{H}}k_{18} = 3.65 \times 10^{-10} \text{ cm}^3 \text{ s}^{-1}$ and fraction of high energy ($> 50 \text{ eV}$) electrons of 3×10^{-4} (see text).

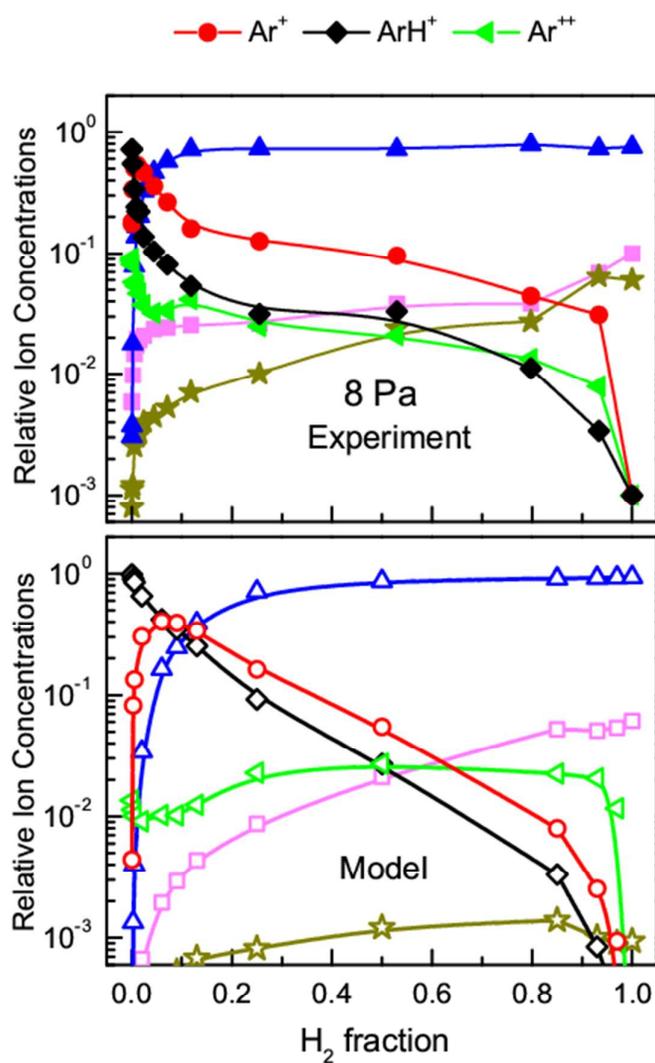


Fig. 5: Relative ion distributions for the 8 Pa discharge. Upper panel: experimental measurements. Lower panel: model simulations with $L_{k18} = 1 \times 10^{-11} \text{ cm}^3 \text{ s}^{-1}$ and a fraction of high energy electrons of 3×10^{-6} .

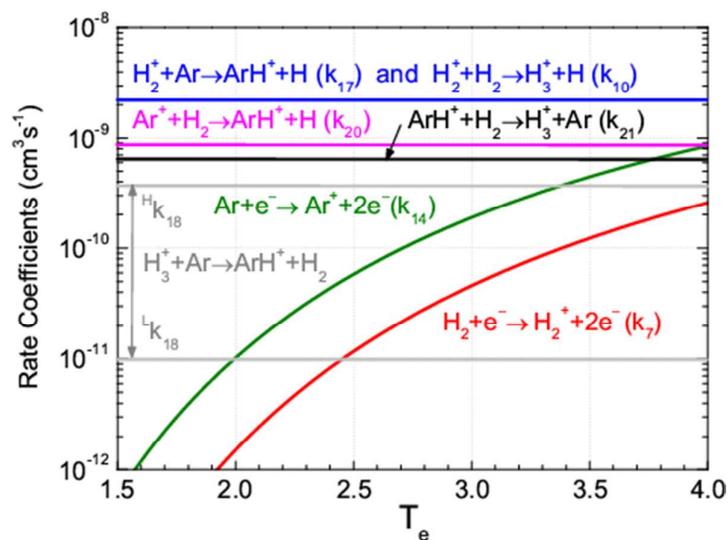


Fig. 6 Rate coefficients for the most relevant electron impact and ion-molecule reactions in the Ar/H₂ discharges as a function of electron temperature. The two values of k_{18} used in the model simulations are shown.

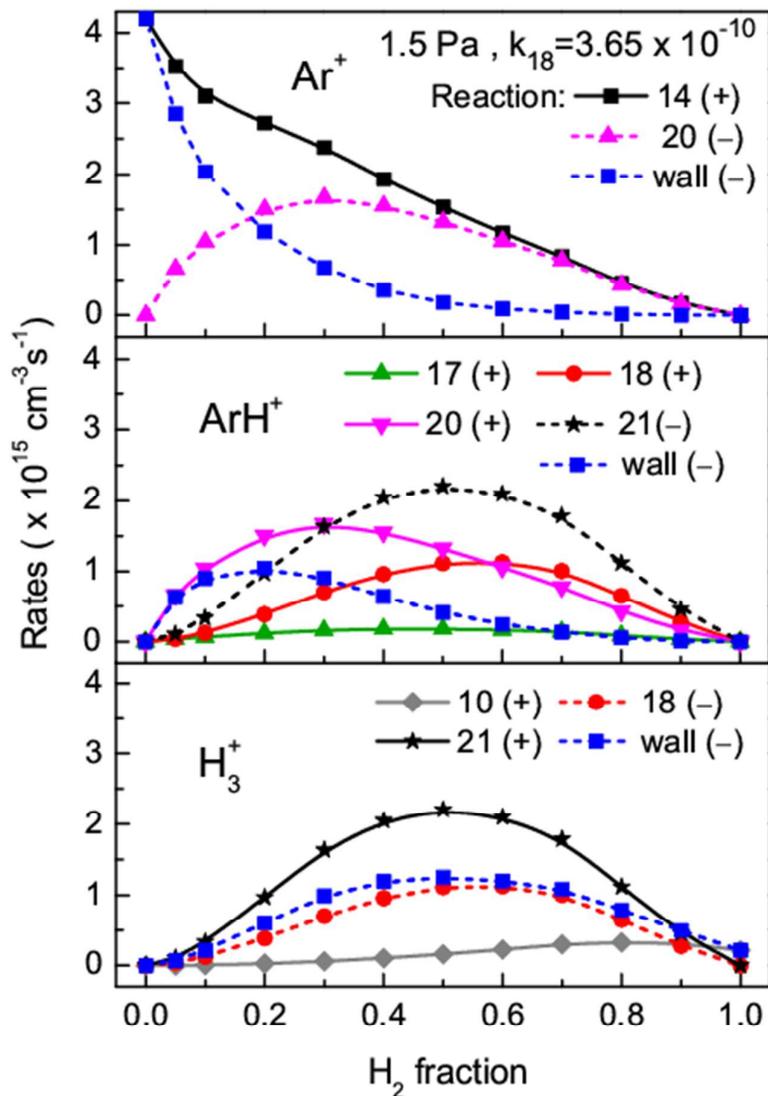


Fig. 7 Rates of the most relevant formation (solid lines and plus signs in parentheses) and loss (dashed lines and minus signs in parentheses) processes for the major ions in the 1.5 Pa Ar/H₂ discharge as a function of the H₂ fraction.

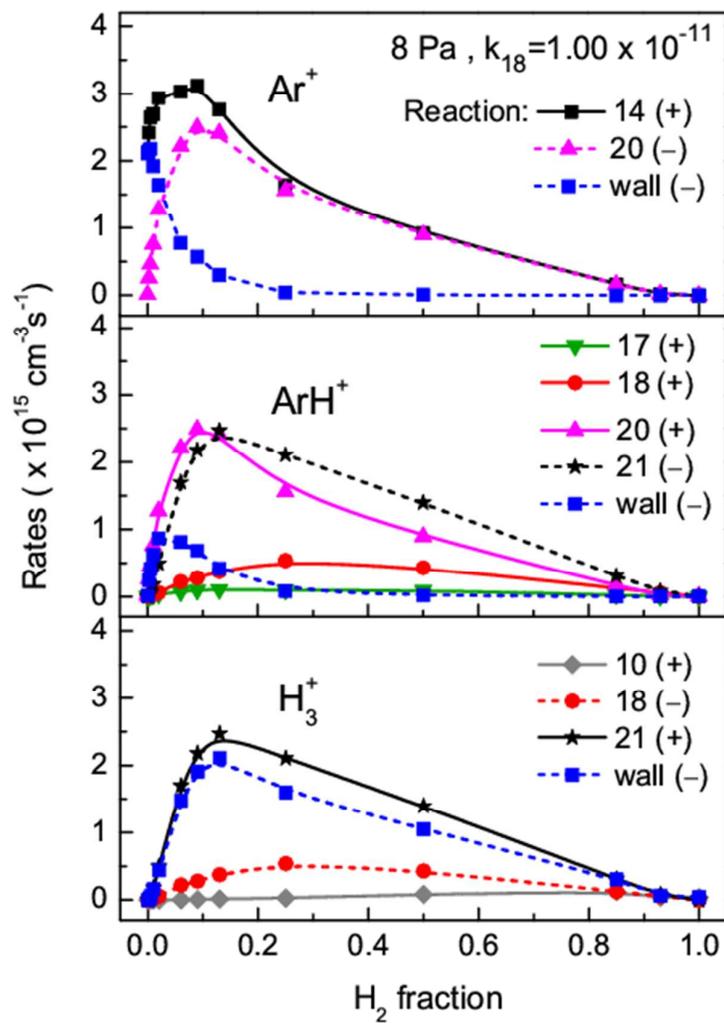


Fig. 8 Same as Figure 7, but for the 8 Pa discharge.